

ISD 2023 - Week 12 Assignment

There are 10 questions for a total of 20 marks.

1. (2 marks) In a two-level system, N_1, N_2 denotes carrier density in the ground and excited state, and A_{ij}, B_{ij} are Einstein's A, B coefficients, respectively (i and j represent a transition from $i \rightarrow j$). Choose the correct rate equation for the spontaneous emission process.

A. $\frac{dN_2}{dt} = A_{21}N_2$

B. $\frac{dN_2}{dt} = B_{21}N_2$

C. $\frac{dN_2}{dt} = -A_{21}N_2$

D. $\frac{dN_2}{dt} = -B_{21}N_2$

E. $\frac{dN_2}{dt} = -B_{21}N_1$

Refer to the lecture.

2. (2 marks) The radiative and non-radiative lifetimes of an emitter are given by τ_r and τ_{nr} , respectively. In which of the following cases will the material be an efficient light emitter?

A. $\tau_r \gg \tau_{nr}$

B. $\tau_r = \tau_{nr}$

C. $\tau_r \ll \tau_{nr}$

D. Emission efficiency of a material is independent of τ_r and τ_{nr} .

Refer to the lecture

Reflect and remember: If the radiative lifetime is larger than the non-radiative lifetime, the light emission becomes inefficient and generates heat. The radiative and non-radiative transition rates, being independent of each other, and their sum result in a total transition rate, which is the inverse of the actual level lifetime.

3. (2 marks) Given below are two statements.

$S1$: Photo-luminescence is a phenomenon of re-emission of light after absorbing a photon of higher energy.

$S2$: Electro-luminescence is a phenomenon of emission of photons by supplying current to the semiconductor.

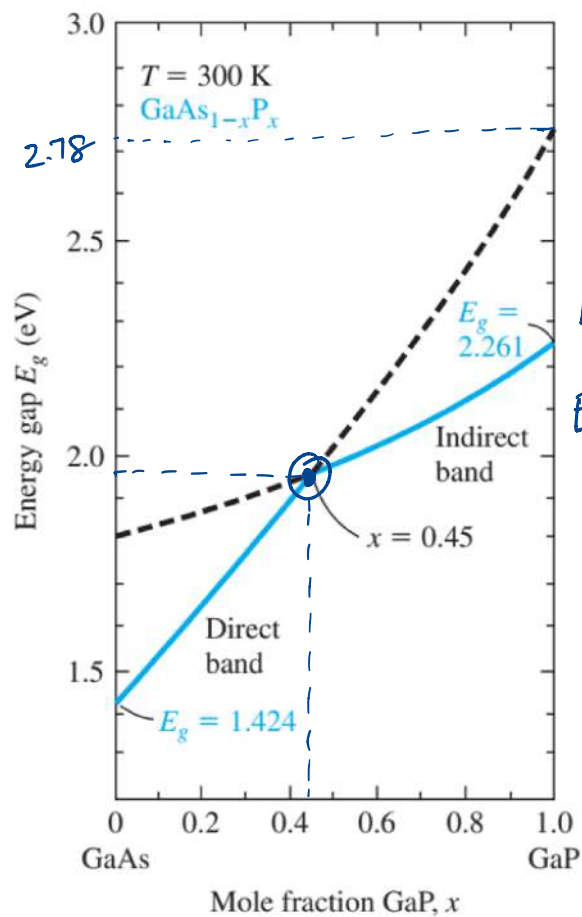
A. Both $S1$ and $S2$ are true.

B. $S1$ is true and $S2$ is false.

C. $S1$ is false and $S2$ is true.

D. Both $S1$ and $S2$ are false.

4. (2 marks) GaP has an indirect bandgap at 2.27 eV and a direct bandgap at 2.78 eV. The band gap of the alloy semiconductor $GaAs_{1-x}P_x$ varies approximately linearly with composition and is a direct bandgap for $0 \leq x \leq 0.45$. The energy gap when $x = 0.45$ and makes alloy composition a direct bandgap material is approximately _____ eV. (bandgap of $GaAs$ is 1.42 eV)



$$E_g - GaAs_{0.55}P_{0.45} - ?$$

Mathematical approx.

$$E_g(x) = 1.42 + 1.36x$$

$$E_g(0.45) = 1.42 + 1.36 \times 0.45 \approx 2 \text{ eV}$$

A. 1.42

B. 2.78

C. 2.27

D. 1.95

Reflect and remember: Consider the case $x > 0.45$, where the semiconductor bandgap becomes indirect and becomes less efficient for optoelectronic devices. For more details, refer to the "Semiconductor Physics and Devices - Basic Principles" by Donald A. Neamen, Fourth Edition Chapter 14.

5. (2 marks) Given below are three statements about bulk materials:

$S1$: LEDs made from Si and Ge are more efficient than LEDs made of GaAs.

$S2$: Si and Ge LEDs cannot emit efficient light as they are indirect bandgap materials.

A. Both $S1$ and $S2$ are true.

B. $S1$ is true and $S2$ is false.

C. $S1$ is false and $S2$ is true.

D. Both $S1$ and $S2$ are false.

6. (2 marks) Given below are two statements.

$S1$: It is difficult to build a blue laser compared to a red laser.

$S2$: Spontaneous emission becomes stronger with decreasing wavelength.

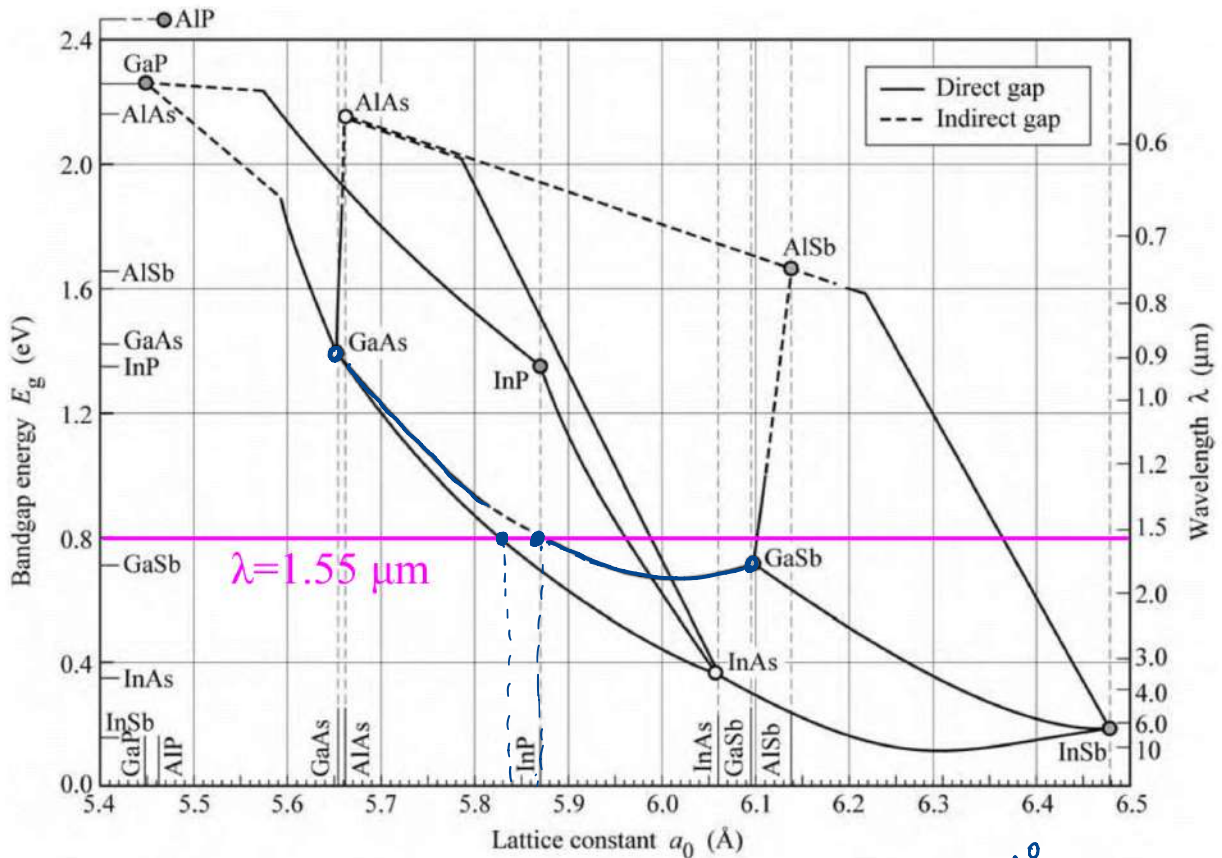
A. $S1$ and $S2$ are true. $S2$ is the correct explanation of $S1$.

B. $S1$ and $S2$ are true. $S2$ is not the correct explanation of $S1$.

C. Both $S1$ and $S2$ are false.

D. $S1$ is false and $S2$ is true.

7. (2 marks) Consider the bandgap-composition graph of III-V compound semiconductors shown in the figure below. Referring to the data in the figure, which compound will you suggest to choose to fabricate a lattice-matched LED on InP substrate at $1.55 \mu\text{m}$?



Lattice matching. $a_0 \sim 5.85 \text{ \AA}$.

A. $\text{Al}_x\text{In}_{1-x}\text{P}$

B. $\text{Ga}_x\text{In}_{1-x}\text{P}$

C. $\text{Ga}_x\text{In}_{1-x}\text{As}$

D. $\text{GaAs}_x\text{Sb}_{1-x}$

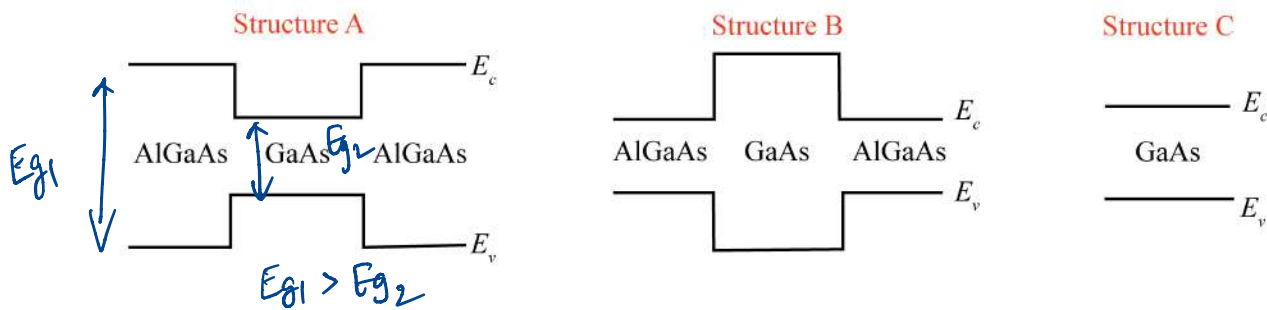
E. $(\text{Al}_x\text{Ga}_{1-x})_{0.5}\text{In}_{0.5}\text{P}$

(i) GaAs - InAs

(ii) GaAs - GaSb

Reflect and remember: For a better light source, the lattice constant (a_0) of the two semiconductors have to be matched, which is referred as **Lattice matching**. As a practice, think about which combination of semiconductors can be used to make a source with 820 nm .

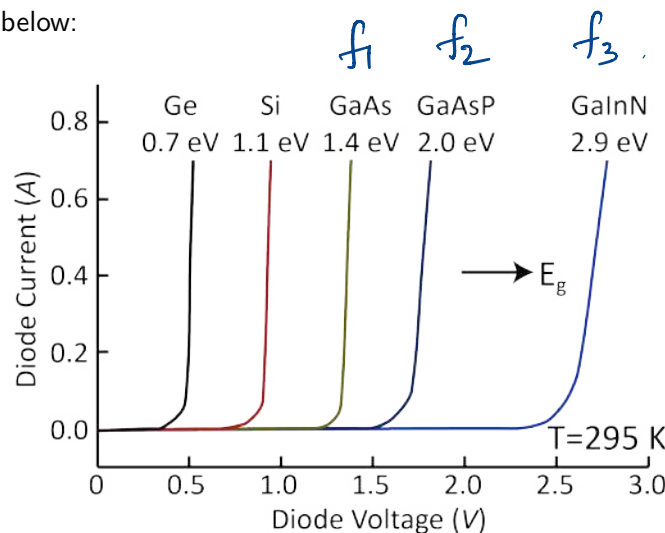
8. (2 marks) Consider the schematics of the structures A, B, C , and one of them can be used for fabricating a laser. Which of the following statements is true?



- A. All the structures as they consist of direct bandgap GaAs material.
- B. Structure A and B as they confine both electrons and photons, being double heterostructures.
- ☒ C. Structure A as it confines both electrons and photons, being a double hetero-structure.
- D. Structure B as it confines both electrons and photons, being a double hetero-structure.
- E. Structure C as it is easy to fabricate.

Reflect and remember: Here, a double Hetero-junction (DH) laser structure consists of a thin layer of narrower bandgap III-V semiconductor (e.g. $E_{g-GaAs} = 1.42 \text{ eV}$) sandwiched between two alloy materials (e.g. p-AlGaAs and n-AlGaAs) with a wider bandgap ($E_{g-AlGaAs} = 2.1 \text{ eV}$), and moreover, the lattice should be matched. For more information, look into the "Semiconductor Physics and Devices - Basic Principles" by Donald A. Neamen Fourth Edition Chapter 14.

9. (2 marks) Consider the I-V characteristics of various light-emitting diodes made up of different materials, as shown in the figure below:



$E_g \rightarrow$

$f \rightarrow$

$V_{th} \rightarrow$

Choose the correct statement with respect to the frequency of light emitted by diodes.

- A. $f_{GaAs} > f_{GaAsP} > f_{GaInN}$
- B. $f_{GaAs} < f_{GaAsP} < f_{GaInN}$**
- C. $f_{Ge} > f_{Si} > f_{GaAs} > f_{GaAsP} > f_{GaInN}$
- D. $f_{Ge} < f_{Si} < f_{GaAs} < f_{GaAsP} < f_{GaInN}$
- E. $f_{GaAs} = f_{GaAsP} = f_{GaInN}$

Reflect and remember: LEDs are a type of PN junctions made of direct bandgap materials. The maximum threshold voltage is achieved when $E_{Fn} \rightarrow E_C$ and $E_{Fp} \rightarrow E_V$ and in the order of the bandgap ($V_{th} \approx E_g/q$). The emission frequency of light (equivalent to their bandgap) can be decided based on the threshold voltage of the diode.

10. (2 marks) Consider the following statements regarding the two-level system with E_1, E_2 denotes the energy levels & N_1, N_2 denotes carrier density in the ground and excited states, respectively.
- S1:** At equilibrium condition, $N_1 > N_2$ and follows Maxwell-Boltzmann distribution.
- S2:** When $N_1 < N_2$, population inversion is achieved, which is the necessary condition for stimulated emission.

Which of the following is true?

- A. Both S1 and S2 are true.**
- B. Both S1 and S2 are false.
- C. S1 is false and S2 is true.
- D. S1 is true and S2 is false.